

光波導分光元件結構之設計與模擬

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摘要

光通訊發展至今，運用高密度分波多工技術來倍增頻寬已成為主流，光通訊元件的需求量也將遽增，其中扮演將光纖的訊號分光與耦合的波導式的分光元件，在未來勢必扮演更重要的角色。本論文探討分光元件中波導式分光器的設計，由於光訊號在波導中的傳輸過程中，包含了波導模態，模態的耦合，損失以及增益等。其他如幾何形狀、波長、初始光場分佈、材料的特性等，牽扯到複雜的運算，為了節省計算的時間，可利用BPM_CAD軟體進行模擬光波導之光路結構。設計上，主要是探討波導的結構對元件的影響，在考慮製程的難易度上，於分光光路間存在一空隙，以避免因製程的不穩定性而造成光路的誤差，而導致分光的不均勻度，此外為了降低元件的損耗，使用S-bend波導作為分光之光路結構，所考慮的是其曲率半徑變化較為緩慢，相對的也降低了因彎曲所造成的輻射損耗。目前已完成 1×4 、 1×8 分光器的設計，在其光場在輸出端之插入損失分別為低於6.5dB、11dB；且均勻度分別低於0.5dB、1dB。進一步設計 1×16 分光器，損耗卻高達17db，比理論值大上許多，故這方面仍有待加強。另外，在製程上是以火焰水解沈積系統沈積光波導膜，目前實驗已完成火焰水解沈積矽石波導層，於4吋之矽晶片上已可製作厚度均勻度3%，折射率均勻度0.1%之石英玻璃膜。相信再配合後續製程，即可達成元件製作之目標，以期能與模擬的結果相互對照。

關鍵詞：高密度分波多工；波導式分光器；火焰水解沈積系統

目錄

第一章 緒論.....	1	第二章 波導及波導模態.....	4	2.1 波導.....	4	2.2 波導模態.....	5	2.3 對稱平板波導與不對稱平板波導的傳播模態.....	7	第三章 數值分析的方					
法.....	9	3.1 為何使用光傳播法.....	9	3.2 光傳播法.....	9	3.3 有限差分傳播				3.4 有效折射率法.....	12	第四章 光路設計.....	14	4.1 概	
述.....	14	4.2 BPM_CAD介紹.....	14	4.3 元件的配置.....	15	4.4 數值分				4.4.1 Taper的寬度變化率.....	17	4.4.2 分光斷點處的空隙大小.....	18	4.4.3	
分析.....	17	4.4.4 S-bend波導.....	19	4.5 製程及其結構參數的討						4.5.1 折射率之差值比.....	20	4.5.2 波導膜的特性.....	21	4.6 模擬結	
論.....	19	4.6.1 1×2 分光器.....	21	4.6.2 1×4 分光器.....	22	4.6.3 1×8 分光				4.6.4 1×16 分光器.....	24	第五章 波導的製作方法與量測.....	25	5.1 波	
導的製作方法及其優點.....	25	5.1.1 火焰水解沈積技術.....	25	5.2 厚度與折射率量						5.2.1 鑽孔式膜厚計.....	27	5.2.2 稜鏡耦合儀.....	27	5.2.2 量測結果討	
測.....	26	5.3 平面波導製作流程.....	28	第六章 結論.....	29										

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